B inding energy of exciton complexes determ ined by the tunnelling current of single electron transistor under optical pumping

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Abstract

We theoretically study the tunnelling current of a single electron transistor (SET) under optical pumping. It found that holes in the quantum dot (QD) created by optical pumping lead to new channels for the electrons tunnelling from emitter to collector. As a consequence, an electron can tunnel through the QD via additional channels, characterized by the exciton, trion and biexciton states. The binding energy of exciton complexes can be determined by the Coulomb oscillatory tunnelling current.

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Recently, the spontaneous emission spectrum of a single quantum dot (QD) has been suggested as a single-photon source, which is important in the application of quantum cryptography 1 4. Experim entally, the spontaneous emission spectrum typically exhibits coexisting sharp emission peaks, which have been attributed to the electron-hole recombination in the exciton, trion, and biexciton form ed in the QD 5 . Nevertheless, it is dicult to experim entally determ ine the binding energy of exciton complexes due to lack of free electron-hole recombination in the QD. In this letter we propose that the tunnelling current of single electron transistor (SET) under optical pum ping can be employed to determ ine the binding energy of exciton. Our calculation is based on the Keldysh Green's function approach within the Anderson model for a two-level system. We nd that the optical excitation creates holes in the QD, which provide new channels (via the electron-hole interaction) for the electron to tunnel from the emitter to the collector. Consequently, an electron can tunnel through the QD via four additional channels, characterized by the exciton, positive trion, negative trion, and biexciton states. Each addition channel can generate a new oscillatory peak in the tunnelling current characteristics in addition to the typical peaks caused by the electron-electron Coulomb interactions. The binding energy of exciton complexes as well as electron charging energy can be determined by using the tunnelling current as functions of gate voltage.

The system under the current study considers a single quantum dot (QD) sandwiched between two leads. Electrons are allowed to tunnel from the left lead (em itter) to the right lead (collector) under the in uence of an optical pump. We start with the following Hamiltonian

$$H = H_d + H_1 + H_{d:1} + H_{d:e} + H_T;$$
 (1)

where the rst term describes electrons in the InAs/GaAsQD. We assume that the quantum connem enterect is strong for the smallQD considered here. Therefore, the energy spacings between the ground state and the rst excited state for electrons and holes, E_e and E_h , are much larger than thermal energy, k_BT , where k_B and T denote the Boltzmann constant and temperature. Only the ground state levels for electrons and holes, E_e and E_h , are considered in H_d . The second term describes the kinetic energies of free electrons in the electrodes, where the correlation electrons, electrons is ignored. Note that in the current setup, the gate electrode does not provide any electrons,

but m erely controls the energy levels of the QD. The third term describes the coupling between the QD and the leads. The fourth term describes the interband optical pumping with a frequency of $!_0$, which is in resonance with the energy dierence between an electron level in the wetting layer and the hole ground state level. Due to the large strain-induced splitting between the heavy-hole and light-hole band for typical QDs, we only have to consider the heavy hole band (with $J_z = 3=2$) and ignore its coupling with light-hole band caused by the QD potential. Because the electron C oulomb interactions is significant in small semiconductor QDs, we take into account the electron C oulomb interactions and electron-hole C oulomb interactions in the last term.

Once the Ham iltonian is constructed, the tunnelling current of SET can be calculated via the Keldysh Green's function method. We obtain the tunnelling current through a single dot

$$J = \frac{2e^{Z}}{h} \frac{d}{2} [f_{L} (_{L}) f_{R} (_{R})] \frac{L()_{R} ()}{L() + R()} Im G_{e}^{r}, ();$$
 (2)

Eq. (2) is still valid for the SET under optical pumping provided that the condition $_{L(R)} >> R_{eh}$ is satisfied, where R_{eh} is the electron-hole recombination rate. $f_{L}()$ and $f_{R}()$ are the Fermi distribution function for the source and drain electrodes, respectively. The chemical potential difference between these two electrodes is related to the applied bias via $_{L} = _{R} = eV_{a}$. $_{L}()$ and $_{R}()$ denote the tunnelling rates from the QD to the left (source) and right (drain) electrodes, respectively. For simplicity, these tunnelling rates will be assumed energy and bias-independent. Therefore, the calculation of tunnelling current is entirely determined by the spectral function $A = Im G_{e}^{r}()$, which is the imaginary part of the retarded G reen's function $G_{e}^{r}()$.

The expression of retarded G reen's function $G_{e;}^{r}$ (), can be obtained by the equation of motion of $G_{e;}^{r}$ (t) = i (t)hfd_e; (t);d_e^y; (0)gi, where (t) is a step function, the curly brackets denote the anti-commutator, and the bracket h:::i represents the thermal average. A fler some algebras⁵, the retarded G reen's function of Eq. (2)

$$G_{e}^{r}, () = (1 N_{e};)f \frac{1 (n_{h}; + n_{h};) + n_{h}; n_{h};}{E_{e} + i - \frac{e}{2}}$$

$$+ \frac{n_{h}; + n_{h}; 2n_{h}; n_{h};}{E_{e} + U_{eh} + i - \frac{e}{2}} + \frac{n_{h}; n_{h};}{E_{e} + 2U_{eh} + i - \frac{e}{2}} g$$

$$+ N_{e}; f \frac{1 (n_{h}; + n_{h};) + n_{h}; n_{h};}{E_{e} U_{e} + i - \frac{e}{2}}$$
(3)

$$+ \frac{n_{h;} + n_{h;}}{E_{e} \quad U_{e} + U_{eh} + i\frac{-e}{2}} + \frac{n_{h;} n_{h;}}{E_{e} \quad U_{e} + 2U_{eh} + i\frac{-e}{2}} g:$$

In Eq. (3), $_{\rm e}$ is the electron tunnelling rate $_{\rm e}$ $_{\rm L}$ + $_{\rm R}$. It is worth noting that the electron-hole recombination e ect have not been directly included into G $_{\rm e}^{\rm r}$; (), because we assumed that $_{\rm e}$ >> R $_{\rm eh}$. The typical value of R $_{\rm eh}$ for InA s/G aA s Q D s is 1=ns. The electron occupation number of the Q D can be solved in a self-consistently via the relation

$$N_{e;} = \frac{Z}{\frac{d}{L_{L_{e}}} f_{L_{e}} () + R_{E_{e}} f_{E_{e}} ()} Im G_{e;}^{r} ();$$
 (4)

 N_{e} ; is limited to the region 0 N_{e} ; 1. Eq. (4) indicates that the electron occupation numbers of the QD, N_{e} ; and N_{e} ;, are primarily determined by the tunnelling process. To obtain the electron and hole occupation numbers (n_{e} ; = n_{e} ; and n_{h} ; = n_{h} ;) arised from the optical pumping, we solve the rate equations and obtain

$$n_e = n_e; = n_e; = \frac{e_{ic}N_{e;k}}{e_{ic}N_{e;k} + R_{eh}n_h + e_{ei}};$$
 (5)

and

$$n_h = n_h; = n_h; = \frac{h_{i,c}N_{h,k}}{h_{i,c}N_{h,k} + R_{eh}(n_e + N_e) + h_i};$$
 (6)

where $_{e(h);c}$ and $N_{e(h);k}$ denote the captured rate for electrons (holes) from the wetting layer to the QD and the occupation number of electrons (holes) in the wetting layer. Here, we assume that $N_{e(h);k}$ is in proportion to the intensity of excitation power, p_{exc} . h denotes the nonradiative recombination rate for holes in the QD.

A coording to Eq. (3), particle Coulom b interactions will sign i cantly a ect the tunnelling current of SET. To illustrate this e ect, we apply our theory to a self-assembled InAs/GaAsQD with pyram idal shape. First, we calculate the inter-particle Coulom b interactions using a simple but realistic e ectivem ass model. The electron (hole) in the QD is described by the equation

$$[r \frac{h^{2}}{2m_{e(h)}(;z)} r + V_{QD}^{e(h)}(;z) eFz]_{e(h)}(r)$$

$$= E_{e(h)}_{e(h)}(r); (7)$$

where $m_e(\cdot;z)$ (a scalar) denotes the position-dependent electron electron electron electron ass, which has $m_{eG}=0.067m_e$ for G aAs and $m_{eI}=0.04m_e$ for InAsQD. $m_h(\cdot;z)$ denotes the position-dependent electron ass tensor for the hole. It is a fairly good approximation to describe $m_h(\cdot;z)$ in InAs/G aAsQD as a diagonal tensor with the x and y components given by $m_t^{-1}=(\cdot_1+\cdot_2)=m_e$ and the z component given by $m_1^{-1}=(\cdot_1+\cdot_2)=m_e$ and $m_e^{-1}=(\cdot_1+\cdot_2)=m_e$ and the z component given by $m_1^{-1}=(\cdot_1+\cdot_2)=m_e$ and $m_e^{-1}=(\cdot_1+\cdot_2)=m_e$ and the z component given by $m_1^{-1}=(\cdot_1+\cdot_2)=m_e$ and $m_e^{-1}=(\cdot_1+\cdot_2)=m_e$ and the z component given by $m_1^{-1}=(\cdot_1+\cdot_2)=m_e$ and the z component given by $m_1^{-1}=(\cdot_1$

$$U_{i,j} = {\overset{Z}{dr_1}} {\overset{Z}{dr_2}} \frac{e^2 \left[n_i (r_1) n_j (r_2) \right]}{0 \, \dot{r}_1 \, r_2 \, \dot{j}};$$
(8)

where $i(j) = e_i h \cdot n_i(r_1)$ denotes the charge density. 0 is the static dielectric constant of InAs. The C oulomb energies are dierent in dierent exciton complexes, but the dierence is small. Therefore, only the direct C oulomb interactions have been taken into account in this study.

For the purpose of constructing the approximate wave functions, we place the system in a large conning cubic box with length L. Here we adopt L = 40nm. The wave functions are expanded in a set of basis functions, which are chosen as sine waves

$$p = \frac{p}{8} \sin(k_1 x) \sin(k_m y) \sin(k_n z);$$
 (9)

where $k_n = n = L_1 k_m = m = L_2 k_n = 1$. In, m and 'are positive integers. The expression of the matrix elements of the Ham iltonian of Eq. (7) can be readily obtained. In our calculation n = 20, m = 10 and '= 10 are used to diagonalize the Ham iltonian of Eq. (7). Fig. 1 shows the interparticle interactions as functions of QD size. The ratio of height and base length is h=b=1=4, while h varies from 2:5nm to 6:5nm. The strengths of Coulomb interactions are inversely proportional to the QD size. However as the QD size decreases below a threshold value (around b=12nm), U_e is significantly reduced due to the leak out of electron density for small QDs. These Coulomb

interactions approach approximately the same value in the large QD limit. This indicates similar degree of localization for electron and hole in large QDs. We also note that U_{eh} is smaller than U_{e} in the large QD. This is due to the fact that in large QDs the degree of localization for the hole becomes similar to that for electron, while the anisotropic nature of hole wave function reduces U_{eh} . The repulsive Coulomb interactions, U_{e} and U_{h} , are the origin of Coulomb blockade for electrons and holes, respectively. The attractive Coulomb interaction U_{eh} gives rise to the binding of the exciton. To study the behavior of tunnelling current, we consider a particular pyramidal InAs/GaAsQD with base length b = 13nm and height h = 35nm. The other relevant parameters for thisQD are $E_{e;0} = 0.14 \text{eV}$, $E_{h;0} = 0.125 \text{eV}$, $U_{e} = 16.1 \text{m eV}$, $U_{eh} = 16.7 \text{m eV}$ and $U_{h} = 18.5 \text{m eV}$.

Now, we perform detailed numerical calculation of the tunnelling current. For simplicity, we assume that the tunnelling rate $_{\rm L} = _{\rm R} = 0.5$ m eV is bias-independent. We apply a bias voltage V_a across the source-drain and V_g across the gate-drain. The QD electron and hole energy levels, E_e and E_h , will be changed to $E_e + eV_a = eV_g$ and $E_h + eV_a = eV_g$, where and are the modulation factors. In our calculation, we assume = 0.5 and = 0.7, which can also be determined by experiments⁹. Meanwhile the chemical potentials of the electrodes with Fermi energy $E_F = 60$ m eV (relative to the conduction band minimum in the leads) are assumed to be 70m eV below the energy level of E_e at zero bias. Parameters $_h = 0.2$ m eV and $R_{eh} = 10$ eV are adopted.

Applying Eqs. (2), (4) and (6), we solve for the electron occupation number $N_e = N_e$; $= N_e$; and tunnelling current J. Fig. 2 shows the calculated results for N_e and J as functions of gate voltage with and without the photon-excitation power at zero temperature and $V_a = 2m V$. Solid line and dashed line correspond to I = 0 (no pump) and I = 0.9 (with pump), respectively. We have defined a dimensionless quantity, $I_{h_f}N_{h_f}k=h_f$, which is proportional to the pump power. The electron occupation number displays several plateaus, while the tunnelling current displays an oscillatory behavior. We label four critical voltages (from V_{g1} to V_{g4}) to indicate the resonance energies of retarded G reen's function. We see that the photon-excitation leads to additional two current peaks below the voltage V_{g3} , which is caused by the electron tunnelling assisted by the presence of a hole in the QD. This interesting phenomenon was observed by Fujiwara et al. in an SET composed of one

silicon (Si) QD and three electrodes. The behavior of the photo-induced tunnelling current can be understood by the analysis of the poles of retarded G reen's function of Eq. (3); the rst peak of dashed line corresponds to the tunnelling current through the energy level at $= E_e$ $2U_{eh}$ (corresponding to a positive trion state). The second peak is caused by a pair of poles at $= E_e$ U_{eh} (the exciton state) and $= E_e + U_e$ $2U_{eh}$ (the biexciton state). Since the magnitude of U_e is very close to that of U_{eh} , these two poles almost merge together. The third peak is caused by another pair of poles at $= E_e$ (the single-electron state) and $= E_e + U_e$ U_{eh} (the negative trion state). The last peak locating near $V_g = 123m$ V is due to the tunnelling current through the energy level at the pole $= E_e + U_e$ (the two-electron state). The gate voltage di erence $V_{g21} = V_{g2}$ V_{g1} ($V_{g43} = V_{g4}$ V_{g3}) determ ine the strength of electron-hole interaction $V_{g21} = U_{eh}$ ($V_{g43} = U_e$). Once U_{eh} is determined, we obtain the binding energy of exciton complexes.

In this study we have used the tunnelling current of an SET under optical pumping to determ ine the electron-hole interaction $U_{\rm eh}$, which can be regarded as the binding energy of exciton. A lithough we used InAs/GaAsSET as an example, this idea can also be applied to Si=SiO₂ SET system 9 .

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Figure Captions

- Fig. 1: Intralevel Coulomb interactions U_e and U_h and interlevel Coulomb interaction U_{eh} as a function of the QD base length b.
- Fig. 2: Electron occupation number N $_{\rm e}$ and tunnelling current as functions of gate voltage at zero temperature for various strengths of optical excitation. Current density is in units of $J_0=2e^{-m}$ m eV=h.

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